# European XFEL Enlightening Science

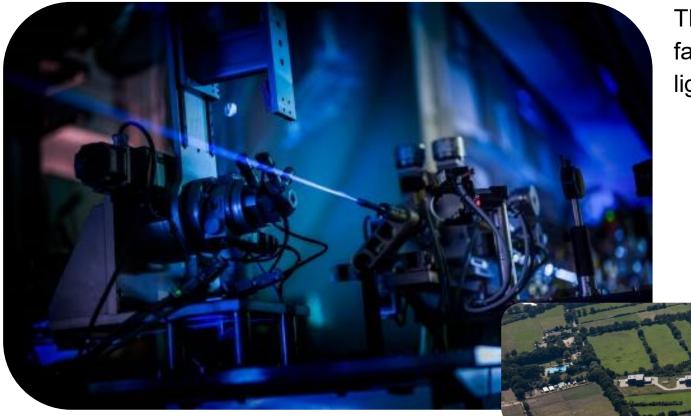
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### **European XFEL**—a leading new research facility



The European XFEL is a new research facility that uses high-intensity X-ray light to study the structure of matter.
User facility with more than 400 employees (+250 from DESY)
Location: Hamburg and Schenefeld, Germany
September 2017: start of user operation

### **About European XFEL**

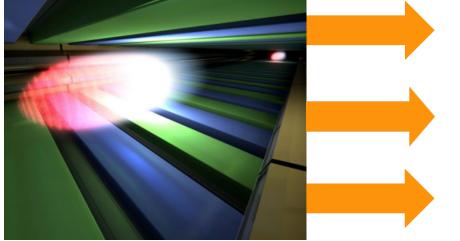


Organized as a non-profit corporation in 2009 with the mission of design, construction, operation, and development of the free-electron laser

Supported by 12 partner countries

- Germany (federal government, city-state of Hamburg, and state of Schleswig-Holstein) covers 57% of the costs; Russia contributes 26%; each of the other international shareholders 1–3%
- Total budget for construction (including commissioning)
  - 1.25 billion € at 2005 prices, about 117 M€ operating budget
  - 600 M€ contributed in cash, over 550 M€ as in-kind contributions (mainly manufacture of parts for the facility)

### What can the European XFEL do?

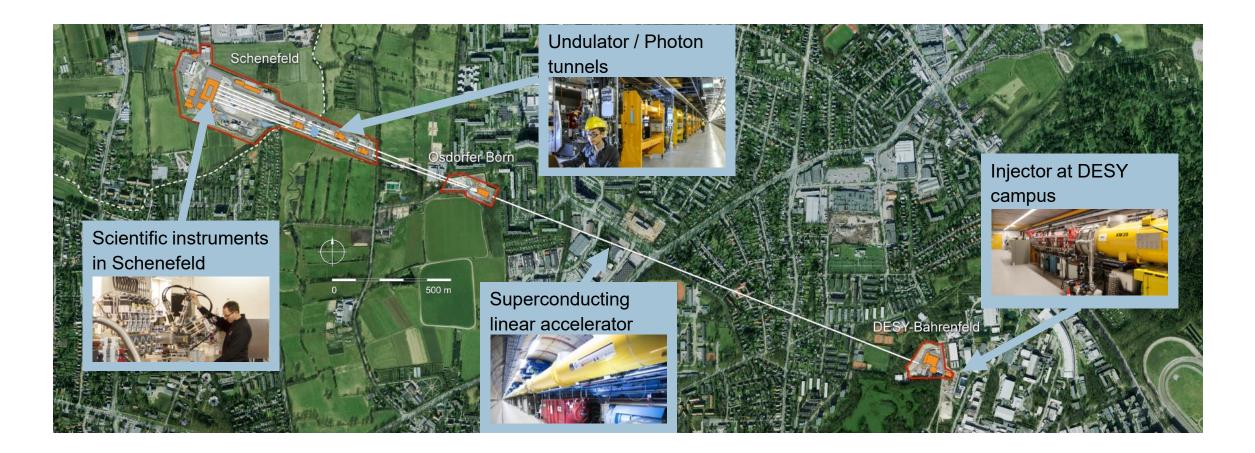


<u>X-ray light</u> See samples at atomic resolution

Ultrashort flashes Film (bio-)chemical reactions

Intense X-ray pulses Study single molecules or tiny crystals

### **General layout of the European XFEL**







Three years of operation including the pandemic situation

1261

23 %

95

**USERS** from across the world have visited European XFEL for their experiments since operation began in September 2017.

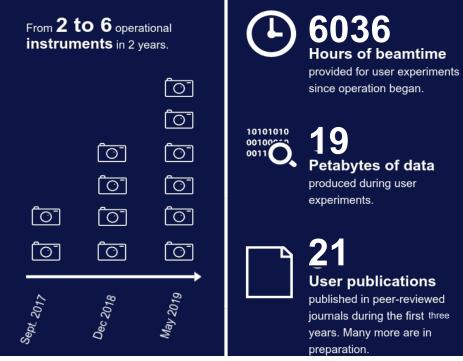


\_\_\_\_ 109 Proposals finished or scheduled (i.e. accepted)

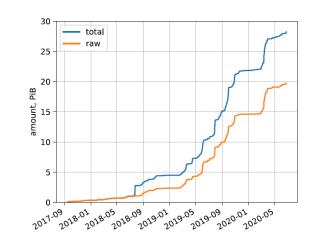
**466** Proposals finished or scheduled (i.e. accepted)

European XFEL

Antonio Bonucci, In kind contribution manager and Industrial Liaison Office



#### Data profile



#### bytes dtype total proc raw instrument SPB 3.2 PiB 8.5 PiB 11.6 PiB 4.6 PiB 7.2 PiB MID 2.7 PiB 2.7 PiB 3.1 PiB **SCS** 352.9 TiB FXE 1.2 PiB 1.3 PiB 2.5 PiB SQS 59.0 TiB 429.4 TiB 488.4 TiB HED 18.4 TiB 25.6 TiB 44.0 TiB 7.5 PiB 17.5 PiB 25.1 PiB total

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### Activity of ILO harmonized with the vision and mission

The office covers tasks that typically in large scale facilities are associated with several offices:

### Supporting state-of-art technologies as IRO/ICO:

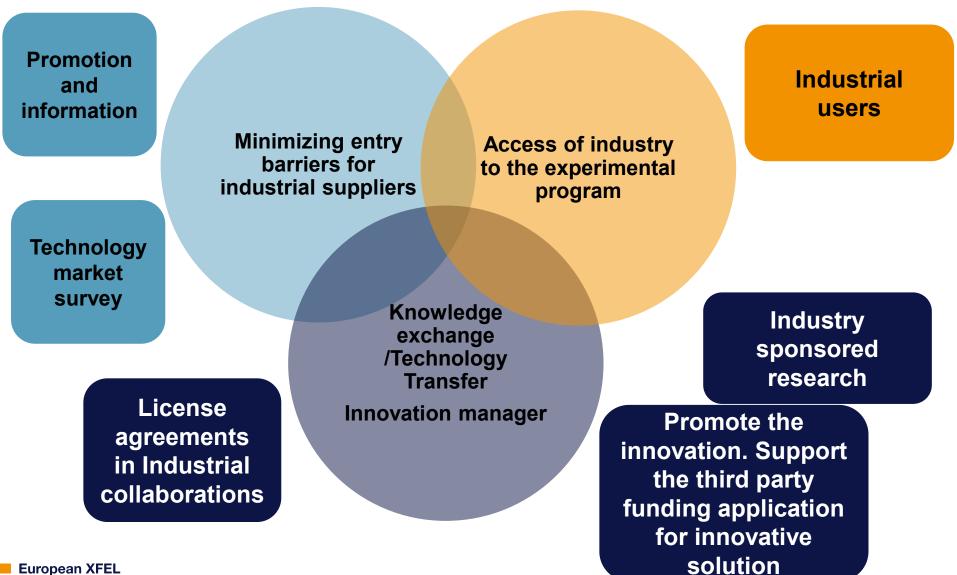
- Minimizing entry barriers for technology providers, in particular for cutting-edge components and challenging specifications
- ► Enlarging the pool of tenders
- Promoting industrial collaborations

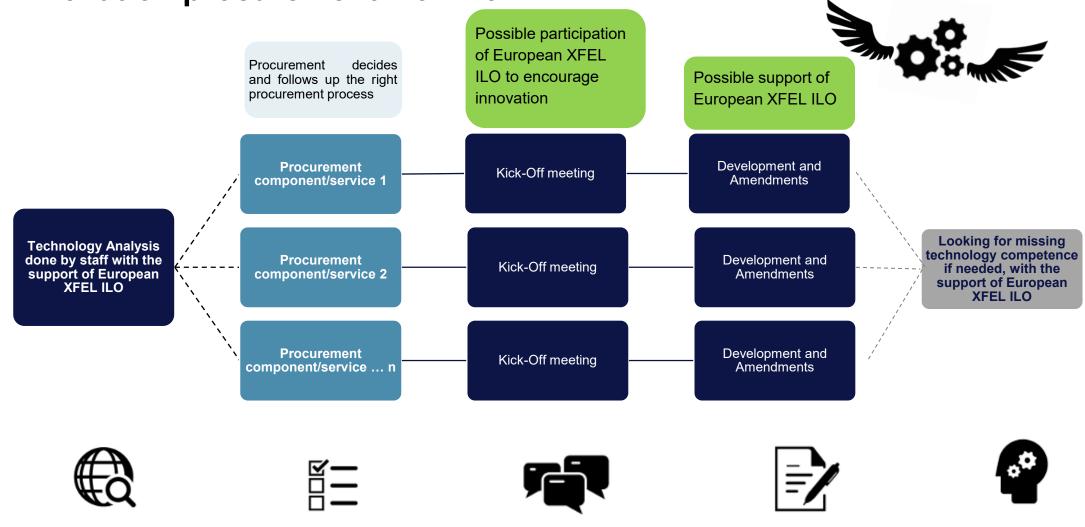
#### Enabling to solve major societal challenges as Industrial User office:

Access of industry to the experimental program, to the lab facilities and knowledge

#### **KTO and TTO towards industry:**

Technology transfer and knowledge transfer towards industry





### **Process of an IKC in the construction phase**



#### European XFEL



|   | Input                       |
|---|-----------------------------|
|   | Extent of contribution      |
|   | Value                       |
|   | Specifications              |
|   | Interfaces                  |
|   | Schedule                    |
| - | Standards & QA requirements |

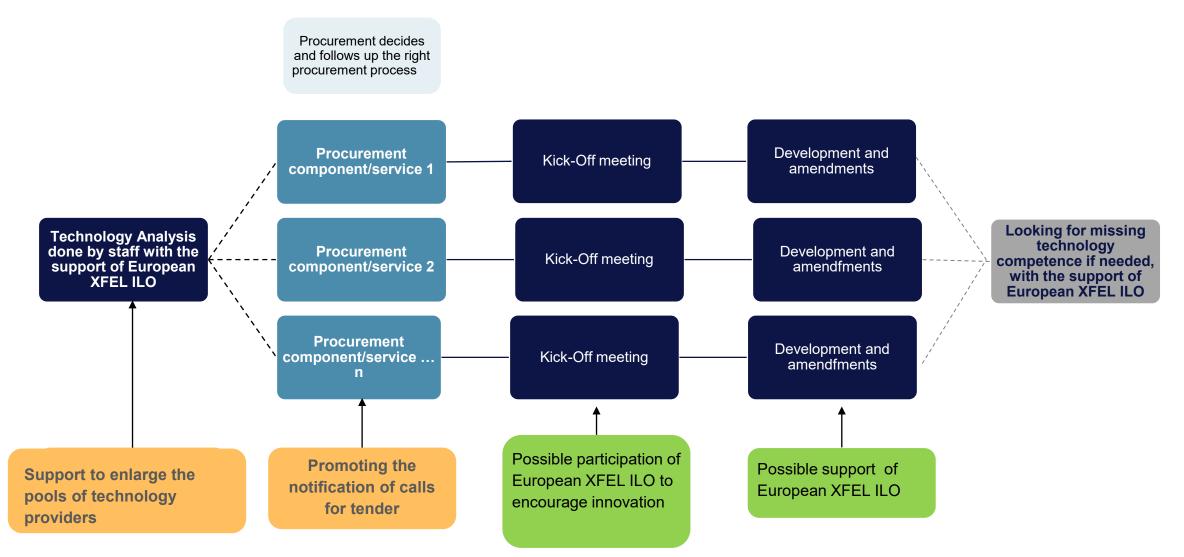
# Project team

- Acceptance tests
- Integration
- Commissioning

### Output

- Hardware
- Services
- Manpower
- Software
- Documents

### Innovation procurement workflow: National ILO involvement



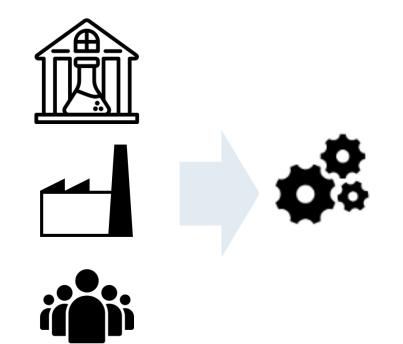
### Intellectual property generation



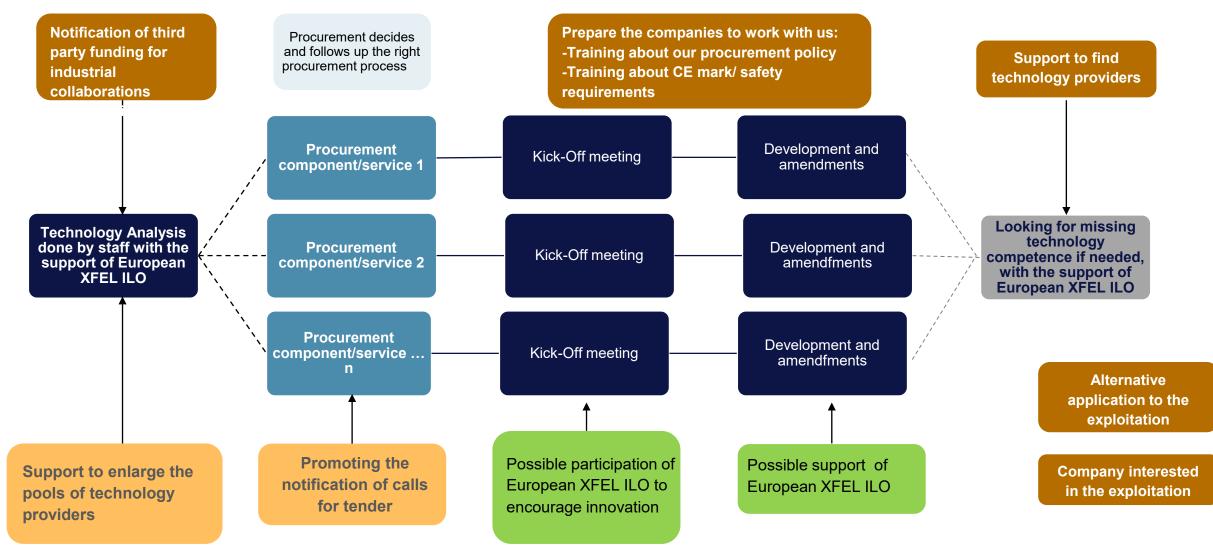
Internal development ready for TT

- In collaboration with our industrial cooperators:
  - Procurement
  - Industrial collaborations
  - Third party funding consortia

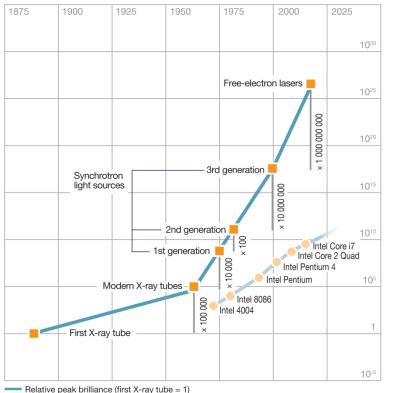




# Innovation procurement workflow: potential national ILO involvment



### Industrial user: preamble Light source development



Number of transistors in processors

The development of light source facilities has been faster than the increase in computer processing capacity (i.e., Moore's Law)

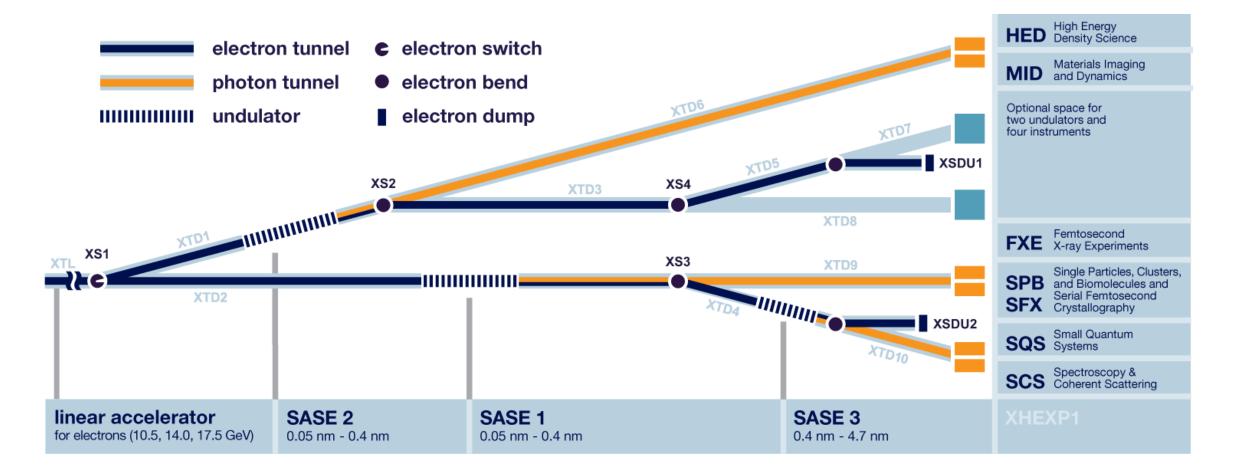
### X-ray free-electron lasers worldwide

| Project                          | LCLS<br>(USA)                                  | LCLS-II<br>CuRF                             | LCLS-II<br>SCRF                          | SACLA<br>(Japan)     | European<br>XFEL     | SwissFEL<br>(CH)      | PAL-XFEL<br>(S. Korea)             | SHINE<br>(China)                   | FERMI (1)                          |
|----------------------------------|--|---|--|----------------------|----------------------|-----------------------|------------------------------------|------------------------------------|------------------------------------|
| Max.<br>electron<br>energy (GeV) | 14.3   | 15  | 5.0                                      | 8.5                  | 17.5                 | 5.8                   | 10                                 | 8                                  | 1.55                               |
| Wavelength range (nm)            | 0.1–4.6  | 0.05–5.0                                    | 0.25–5.0                                 | 0.06–0.3             | 0.05–4.7             | 0.1–7                 | 0.06–10                            | 0.05–3.1                           | 4-100                              |
| Photons/pul<br>se                | ~10 <sup>12</sup>                              | 2 x 10 <sup>13</sup>                        | <b>3 x10</b> <sup>13</sup> (soft X-rays) | 2 x 10 <sup>11</sup> | ~10 <sup>12</sup>    | ~5 x 10 <sup>11</sup> | 10 <sup>11</sup> –10 <sup>13</sup> | 10 <sup>10</sup> –10 <sup>13</sup> | 10 <sup>11</sup> –10 <sup>14</sup> |
| Peak<br>brilliance               | 2.7 x<br>10 <sup>34</sup><br>(with<br>seeding) | 2.7 x 10 <sup>34</sup><br>(with<br>seeding) | 1 x 10 <sup>32</sup>                     | 1 x 10 <sup>33</sup> | 5 x 10 <sup>33</sup> | 1 x 10 <sup>33</sup>  | 1.3 x 10 <sup>33</sup>             | 1 x 10 <sup>33</sup>               | 10 <sup>30</sup> –10 <sup>32</sup> |
| Pulses/seco<br>nd                | 120  | 120   | 1 000 000                                | 60                   | 27 000               | 100                   | 60                                 | 1 000 000                          | 10-50                              |
| Date of first<br>beam            | 2009   | 2019  | 2020                                     | 2011                 | 2017                 | 2016                  | 2016                               | 2025                               | 2010                               |

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(1) Courtesy of Dr. Marco Peloi, Head of Industrial Liaison Office Elettra - Sincrotrone Trieste SCpA

### Industrial user: preamble Beamline layout and experiment stations

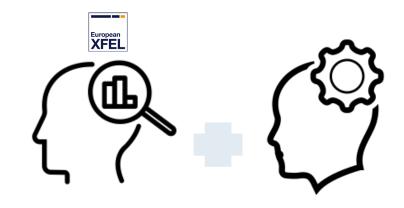


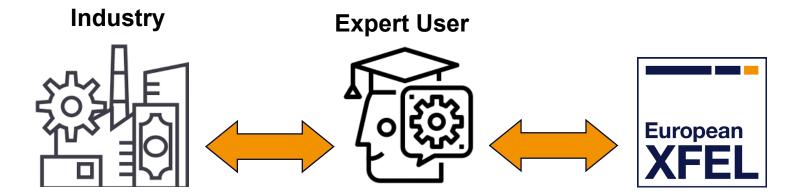
### Industrial user: first approach

We don't make measurements

New users with new experiments need ad-hoc developments

... industrial users can be industrial collaborators



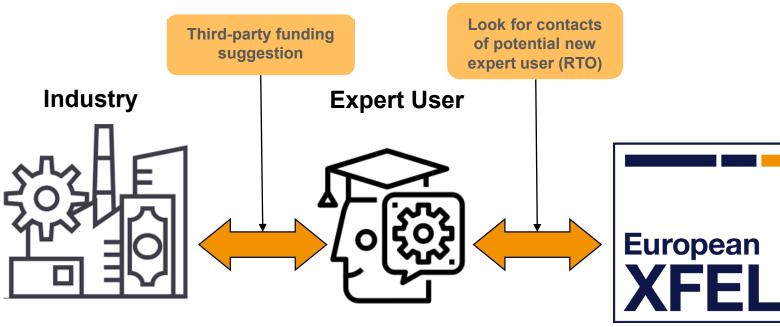




European

### Industrial user: first approach and potential national ILO involvement

- We don't make measurements
- New users with new experiments need ad-hoc developments
- ... industrial users can be industrial collaborators





19

### Conclusion

The industrial network of the national ILO is an extremely important resource for the development of our facilities

National ILOs are currently involved in the procurement process

### National ILOs can be also involved:

- In the training of the industrial co-operators to facilitate the collaboration with the facilities
- Suggestion of expert users in industrial collaboration for new experiments in the area of applied science
- Suggestion of third party funding for industrial collaboration
- In the exploitation phase of the IP, looking for interested companies

### LEAPS & HR4tech

- **LEAPS** the League of European Accelerator-based Photon Sources – is a strategic consortium initiated by the Directors of the Synchrotron Radiation and Free Electron Laser user facilities
  - **LEAPS** consists of 16 organisations representing 19 light source facilities across Europe





One of the current leading LEAPS projects - **HR**<sup>4</sup>**tech** – celebrates proactive innovation and industrial exchange through fostering of industrial ecosystem within LEAPS facilities.

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